

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	Toru KIMURA <i>et al.</i>	Confirmation No.:	4887
Application No.:	10/586,187	Examiner:	JOHNSON, CONNIE P.
Filed:	July 31, 2007	Group Art Unit:	1722

For: UPPER LAYER FILM FORMING COMPOSITION FOR LIQUID
IMMERSION AND METHOD OF FORMING PHOTORESIST PATTERN

Commissioner for Patents
Alexandria, VA 22313-1450

AMENDMENT UNDER 37 C.F.R. § 1.111

Dear Sir:

In response to the non-final Office Action dated October 24, 2011, please reconsider the above-identified application based on the following:

AMENDMENT AND PRESENTATION OF CLAIMS	2
REMARKS	6